NOTES:

1. SUBSTRATE:

FUSED SILICA

2. COATING (APPLY ACROSS CLEAR APERTURE)

\$1: Ultrafast (870-970nm)

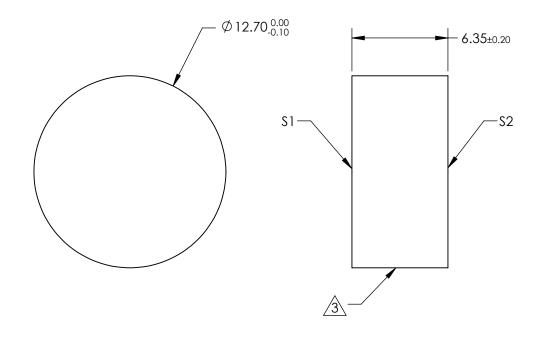
R(AVG) S&P > 99.90% @ 920nm R(AVG)> 99.7% @ 870 - 970nm

GDD SPECIFICATION: ±20 fs2@ 870 - 970nm @ 45° AOI

S2: NONE



4. ROHS COMPLIANT



FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	\$1	\$2				Edmund Optic	C®
SHAPE	PLANO	PLANO					,S
SURFACE QUALITY	10 - 5	COMMERCIAL POLISH		1		Low-GDD Ultrafast Dielectric Mirror, 920	nm
CLEAR APERTURE	Ø11.43	N/A	THIRD ANGLE PROJECTION		TITLE	45° AOI, 12.7mm Dia., 6.35mm Thick	
SURFACE FLATNESS	λ/8	N/A				40 /(O), 12./11111 Bld., 0.0011111 Tillek	CLIEFT
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	ALL DIMS IN	mm	DWG NO	26832	SHEET 10 OF 24